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## **Search Results -** Record(s) 1 through 2 of 2 returned.

\_\_\_\_\_ 1. Document ID: US 6349669 B1

L3: Entry 1 of 2

File: USPT

Feb 26, 2002

US-PAT-NO: 6349669

DOCUMENT-IDENTIFIER: US 6349669 B1

TITLE: Method and apparatus for depositing a thin film, and semiconductor device having a <u>semiconductor-insulator</u> junction

Full Title Citation Front Review Classification Date Reference Sequences Attachments Claims KMC Draw, Descriptings

2. Document ID: US 6069094 A

L3: Entry 2 of 2

File: USPT

May 30, 2000

US-PAT-NO: 6069094

DOCUMENT-IDENTIFIER: US 6069094 A

TITLE: Method for depositing a thin film

Full Title Citatio	n Front Review	Classification	Date	Reference	Sequences	Attachments	Claims	ΚŅ
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\_\_\_\_\_ 1. Document ID: US 5254488 A

L2: Entry 1 of 1

File: USPT

Oct 19, 1993

US-PAT-NO: 5254488

DOCUMENT-IDENTIFIER: US 5254488 A

TITLE: Easily manufacturable thin film transistor structures

Full Title Citation  Draw. Desc   Image	Front Review Classification Date F	Reference   Sequences   Attachments	į ki
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